

<https://www.spst-photopolymer.org>

Call for Papers

ICPST-42

The 42nd International Conference of
Photopolymer Science and Technology

Materials & Processes for Advanced Lithography,
Nanotechnology and Phototechnology

June 24 - 27, 2025

**Arcrea HIMEJI,
Himeji City, Hyogo, Japan**

**Sponsored by the Society of Photopolymer
Science and Technology (SPST)**

In Cooperation with
The Technical Association of
Photopolymers, Japan
The Chemical Society of Japan
The Society of Polymer Science, Japan
The Japan Society of Applied Physics, Japan



Introduction

The 42nd International Conference of Photopolymer Science and Technology, Materials & Processes for Advanced Lithography, Nanotechnology and Phototechnology (**ICPST-42**) organized by **SPST** will be held at Arcrea HIMEJI, Himeji City, Hyogo, Japan, on June 24-27, 2025. The details will appear at the SPST Homepage.

All the contributors of papers on the scientific progress and the technical development of photopolymers are cordially invited.

Scopes

The conference covers a wide range of topics relevant to photopolymer science and technology in the following fields:

A. English Symposia

- A0. Plenary Talk
- A1. Next Generation Lithography, EB Lithography and Nanotechnology
- A2. Nanobiotechnology
- A3. Directed Self Assembly (DSA)
- A4. Computational / Analytical Approach for Lithography Processes
- A5. EUV Lithography
- A6. Nanoimprint
- A7. 193 nm Lithography Extension
- A8. Photopolymers in 3-D Printing/ Additive Manufacturing
- A9. Strategies and Materials for Advanced Packaging, Next Generation MEMS, Flexible Devices
- A10. Chemistry for Advanced Photopolymer Science
- A11. Organic and Hybrid Materials for Photovoltaic and Optoelectronic Devices
- A12. Fundamentals and Applications of Biomimetics Materials and Processes
- A13. Polyimides and High Thermally Stable Resins
- A14. General Scopes of Photopolymer Science and Technology
- P. Panel Symposium

B. Japanese Symposia

- B1. Polyimides and High Thermally Stable Resins
-Functionalization and Practical Applications-
- B2. Plasma Photochemistry and Functionalization of Polymer Surfaces
- B3. General Scopes of Photopolymer Science and Technology

C. Tutorial Session

Under consideration

Language and Oral Presentation Time

English is used for presentations in English Symposia and Panel Symposium. Both Japanese and English are used for presentations in Japanese Symposia and Tutorial Session. Each presentation will not be longer than 20 minutes including discussion except for the notified lectures.

Application to Scientific Program

Apply to [Conference → Presentation-Information Submission] at the SPST Homepage (<https://www.spst-photopolymer.org/>) before **February 14, 2025**.

Editorial Office

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Papers

Papers submitted to ICPST-42 are published in Journal of Photopolymer Science and Technology, Vol. 38 (2025) after reviewing on the Journal's standard. Journal will be distributed to each participant during the conference. Preparation of manuscripts for the Journal should be followed to "Instructions to Authors" and "Manual for Manuscript Writing". Refer "Page Layout Sample" and use "Sample Manuscript (Manuscript Template)". Submit the manuscripts to [Journal → Submission & Reviewing of MS] at the SPST Homepage before **April 1, 2025**. The Journal will be published and mailed before ICPST-42.

Membership Fees (Including ICPST-42 Participants and its Journal)

All the participants including speakers are requested to register in [Conference → Registration] at the SPST Homepage.

	By May 31, 2025	From June 1, 2025
Regular Registration	65,000 JPY	80,000 JPY
Student Registration	10,000 JPY	15,000 JPY
Banquet	5,000 JPY	5,000 JPY

※ In consideration of the recent rise in prices and ongoing operations, SPST has decided the membership fees.

Conference Office

The 42nd International Conference of Photopolymer Science and Technology (ICPST-42)

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The Society of Photopolymer Science and Technology (SPST)

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Director of Awards:	Itaru Osaka
Director of Administration:	Hiroto Kudo

ICPST-42 International Advisory Board

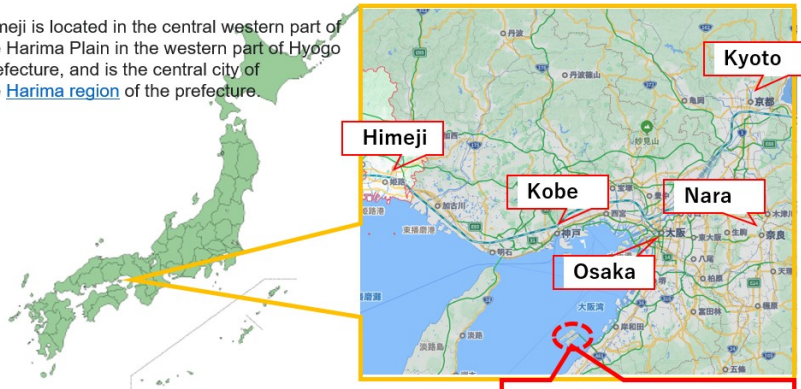
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Himeji City, Hyogo, Japan

Location

Himeji is located in the central western part of the Harima Plain in the western part of Hyogo Prefecture, and is the central city of the [Harima region](#) of the prefecture.



Himeji Castle (姫路城, *Himeji-jō*) is a hilltop [Japanese castle](#) complex situated in [Himeji](#), a city in the [Hyōgo Prefecture](#) of [Japan](#). The castle is regarded as the finest surviving example of prototypical Japanese castle architecture, comprising a network of 83 rooms with advanced defensive systems from the [feudal period](#).^[1] The castle is frequently known as [Hakuro-jō](#) or [Shirasagi-jō](#) ("White [Egret](#) Castle" or "[White Heron](#) Castle") because of its brilliant white exterior and supposed resemblance to a bird taking flight

Kansai International Airport ([Japanese](#): 関西国際空港, [romanized](#): *Kansai Kokusai Kūkō*), commonly known as **Kankū** ([Japanese](#): 関空) ([IATA](#): **KIX**, [ICAO](#): **RJBB**), is the primary [international airport](#) in the [Greater Osaka Area](#) of Japan and the closest international airport to the cities of [Osaka](#), [Kyoto](#), and [Kobe](#). It is located on an [artificial island](#) ([Kankūjima](#) (関空島)) in the middle of [Osaka Bay](#) off the [Honshū](#) shore, 38 km (24 mi) southwest of [Osaka Station](#).^[1] located within three municipalities, including [Izumisanō](#) (north), [Sennan](#) (south), and [Tajiri](#) (central), in [Osaka Prefecture](#).



Arcrea HIMEJI

Arcrea Himeji is brand new convention center at Himeji City, and it is 10 min walk from the JR Himeji Station at which Shinkansen stops.

[Himeji City | Arcrea HIMEJI](#)



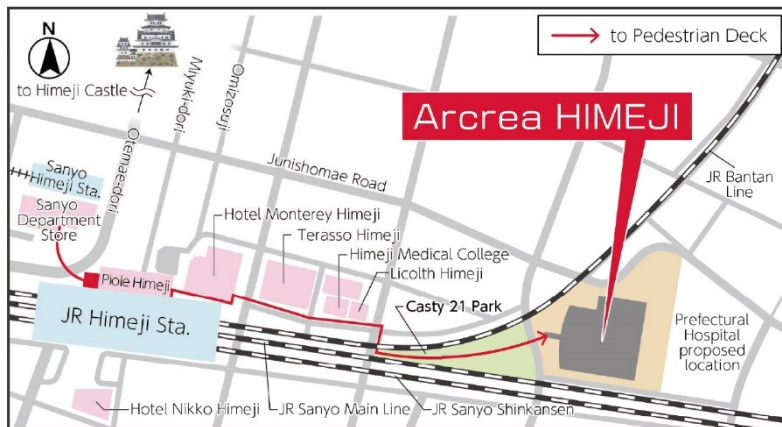
Hotel informations

Hotel Nikko Himeji, Richmond Hotel Himeji, Natural Hot Spring Dormy Inn Himeji, Himeji Castle Grandvrio Hotel, Hotel Monterey Himeji, Toyoko Inn Shinkansen Himeji-eki Kita-guchi, APA Hotel Himeji Ekikita, Toyoko Inn Shinkansen Himeji-eki Minami-guchi, Daiwa Roynet Hotel, Hotel Wing International Himeji, Natural Hot Spring Hotel LiVEMAX PREMIUM Himejeki-Minami, JR Clement Inn Himeji, Comfort Hotel Himeji, Hotel Livemax Himeji Ekimae, Himeji Ekimae Universal Hotel Minamiguchi, Hotel Fosse Himeji, Hotel Alpha-One Himeji Minamiguchi, Himeji Green Hotel

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Transportations

[Himeji City | Arcrea HIMEJI](#)



By Plane from Kansai International Airport, Osaka Itami Airport, and Kobe Airport

